L Number	Hits	Search Text	DB	Time stamp
- Namper	1815	(phase adj shift\$3 same (mask or photomask	USPAT;	2003/04/30 14:30
	1010	or reticle)) same (resist or photoresist	US-PGPUB;	2003, 01, 30 11.30
		or photosensit\$4)	EPO; JPO;	
	!	or photocontrol in	IBM TDB	
_	798	((phase adj shift\$3 same (mask or	USPAT;	2003/04/28 16:37
		photomask or reticle)) same (resist or	US-PGPUB;	
		photoresist or photosensit\$4)) and (trim	EPO; JPO;	
	1	or ((mask or photomask or reticle) near3	IBM TDB	
		set) or (second or complementary) adj		
		(mask or photomask or reticle) or		
		overla\$5)		
-	126	(((phase adj shift\$3 same (mask or	USPAT;	2003/04/28 16:25
	,	photomask or reticle)) same (resist or	US-PGPUB;	
	1	photoresist or photosensit\$4)) and (trim	EPO; JPO;	
		or ((mask or photomask or reticle) near3	IBM TDB	
		set) or (second or complementary) adj	_	
	.	(mask or photomask or reticle) or		
		overla\$5)) and (transistor near3 gate or		
		gate adj shr?nk\$3)		
-	97	((((phase adj shift\$3 same (mask or	USPAT;	2003/04/28 16:25
		photomask or reticle)) same (resist or	US-PGPUB;	
		photoresist or photosensit\$4)) and (trim	EPO; JPO;	
ĺ	,	or ((mask or photomask or reticle) near3	IBM_TDB .	
		set) or (second or complementary) adj		
		(mask or photomask or reticle) or		
		overla\$5)) and (transistor near3 gate or		
		gate adj shr?nk\$3)) and (resolution or		
	89	resolv\$3)	HCDAM.	2002/04/20 16:26
-	69	(((((phase adj shift\$3 same (mask or	USPAT;	2003/04/28 16:26
		photomask or reticle)) same (resist or photoresist or photosensit\$4)) and (trim	US-PGPUB; EPO; JPO;	
		or ((mask or photomask or reticle) near3	IBM TDB	
		set) or (second or complementary) adj	1511_155	
		(mask or photomask or reticle) or		
		overla\$5)) and (transistor near3 gate or		
		gate adj shr?nk\$3)) and (resolution or		
		resolv\$3)) and (optical adj (parameter or		
		configurat\$3) or aperture or (wavelength		
		or coherenc\$1 or illumina\$4 or focus or		
		defocus) same (expos\$3 or radia\$4 or		
		irradia\$4 or light or illumina\$4))		
-	65	(((((phase adj shift\$3 same (mask or	USPAT;	2003/04/28 16:28
		photomask or reticle)) same (resist or	US-PGPUB;	
		photoresist or photosensit\$4)) and (trim	EPO; JPO;	
		or ((mask or photomask or reticle) near3	IBM_TDB	.
		set) or (second or complementary) adj		
		(mask or photomask or reticle) or		
	İ	overla\$5)) and (transistor near3 gate or		
		gate adj shr?nk\$3)) and (resolution or		
	,	resolv\$3)) and (optical adj (parameter or		
		configurat\$3) or aperture or (wavelength		
		or coherenc\$1 or illumina\$4 or focus or		
		defocus) same (expos\$3 or radia\$4 or		
		irradia\$4 or light or illumina\$4))) and		
L	l	(dose or dosage or intensity)	<u> </u>	

Page 1

				1 0000 /04 /00 16 00
-	24	3	USPAT;	2003/04/28 16:28
		<pre>photomask or reticle)) same (resist or photoresist or photosensit\$4)) and (trim</pre>	US-PGPUB; EPO; JPO;	
		or ((mask or photomask or reticle) near3	IBM TDB	
		set) or (second or complementary) adj	TBM_TDB	
		(mask or photomask or reticle) or		
		overla\$5)) and (transistor near3 gate or		
		gate adj shr?nk\$3)) and (resolution or		
		resolv\$3)) and (optical adj (parameter or		
!		configurat\$3) or aperture or (wavelength		1
,		or coherenc\$1 or illumina\$4 or focus or		
		defocus) same (expos\$3 or radia\$4 or		
,		irradia\$4 or light or illumina\$4))) not		
		(((((((phase adj shift\$3 same (mask or		
1		photomask or reticle)) same (resist or		
		photoresist or photosensit\$4)) and (trim		
		or ((mask or photomask or reticle) near3	İ	1
		set) or (second or complementary) adj		
		(mask or photomask or reticle) or		
		overla\$5)) and (transistor near3 gate or		
1		gate adj shr?nk\$3)) and (resolution or		
		resolv\$3)) and (optical adj (parameter or		
		configurat\$3) or aperture or (wavelength		
		or coherenc\$1 or illumina\$4 or focus or		
		defocus) same (expos\$3 or radia\$4 or		
		irradia\$4 or light or illumina\$4))) and		
	Ì	(dose or dosage or intensity))		
_	2	(("20020187636") or ("20020197543")).PN.	USPAT;	2003/04/28 16:33
			US-PGPUB;	
			EPO; JPO;	
			IBM TDB	
-	22	(("6284419") or ("6519501") or	USPĀT;	2003/04/28 16:34
		("20020076622") or ("6453457") or	US-PGPUB;	
1	ĺ	("6337172") or ("6541165") or ("6503666")	EPO; JPO;	
	!	or ("6162568") or ("6255024") or	IBM_TDB	
		("6268091") or ("6319644") or ("6421111")		
		or ("5972569") or ("5405721") or		
		("6042973") or ("6127096") or ("6374396")		
		or ("6096457") or ("6106979") or		_
		("6040892") or ("6120952") or		1
		("5741624")).PN.		
-	21	(((("20020187636") or	USPAT;	2003/04/28 16:35
		("20020197543")).PN.) or ((("6284419") or	US-PGPUB	
		("6519501") or ("20020076622") or		
		("6453457") or ("6337172") or ("6541165")		
		or ("6503666") or ("6162568") or		
,		("6255024") or ("6268091") or ("6319644")		
		or ("6421111") or ("5972569") or		
		("5405721") or ("6042973") or ("6127096") or ("6374396") or ("6096457") or		•
	ļ	("6106979") or ("6040892") or ("6120952")		
		or ("5741624")).PN.)) not (((((phase adj		
		shift\$3 same (mask or photomask or		
		reticle)) same (resist or photoresist or		
		photosensit\$4)) and (trim or ((mask or		
		photomask or reticle) near3 set) or		
		(second or complementary) adj (mask or		
		photomask or reticle) or overla\$5)) and		
		(transistor near3 gate or gate adj		
		shr?nk\$3)) and (resolution or resolv\$3))		
		and (optical adj (parameter or		
		configurat\$3) or aperture or (wavelength		
		or coherenc\$1 or illumina\$4 or focus or		
		defocus) same (expos\$3 or radia\$4 or	'	
		irradia\$4 or light or illumina\$4)))		

		//420/E 211 210 210 204 206 255/E2 22	HODAG	1 2002 /05 /12 10 22
	398	((430/5,311-312,319,394,396 or 355/53,77 or 378/34-35 or 716/19-21).ccls. and (phase adj shift\$3 same (mask or photomask or reticle)) same (trim or ((mask or photomask or reticle) near3 set) or (second or complementary) adj (mask or photomask or reticle) or overla\$5)) not (((((phase adj shift\$3 same (mask or photomask or reticle)) same (resist or photomask or reticle)) same (resist or photoresist or photosensit\$4)) and (trim or ((mask or photomask or reticle) near3 set) or (second or complementary) adj (mask or photomask or reticle) or overla\$5)) and (transistor near3 gate or gate adj shr?nk\$3)) and (resolution or resolv\$3)) and (optical adj (parameter or configurat\$3) or aperture or (wavelength or coherenc\$1 or illumina\$4 or focus or defocus) same (expos\$3 or radia\$4 or irradia\$4 or light or illumina\$4)) (("5885734") or ("6077630") or ("20010000240") or ("20010028985")).PN.	USPAT; US-PGPUB; EPO; JPO; IBM_TDB USPAT; US-PGPUB	2003/05/13 18:22
_	48	("20010000240") or ("20010028985")).PN.	USPAT;	2003/04/30 14:58
		or ("5308741") or ("4436371") or ("5308747") or ("5308741") or ("5316878") or ("5324600") or ("5328807") or ("5334542") or ("5352550") or ("5364716") or ("5496666") or ("5498579") or ("5503951") or ("5523186") or ("5527645") or ("5532090") or ("5537648") or ("5538815") or ("5539568") or ("556286") or ("5573890") or ("5595843") or ("5620816") or ("57635316") or ("57620816") or ("5766804") or ("5766804") or ("5766806") or ("5766804") or ("5766806") or ("5827623") or ("5885734") or ("5923566") or ("5994002") or ("5998068") or ("6004702") or ("5998068") or ("6004702") or ("6010807") or ("6057063") or ("6066180") or ("6228539") or ("6251549") or ("6228539") or ("6251549") or ("6258493")).PN.	US-PGPUB	2505/04/50 14.30
_	9	(("5472814") or ("5923562") or ("6130012") or ("6139994") or ("6185727") or ("6335128") or ("6338922") or ("20010000240") or ("20010028985")).PN.	USPAT; US-PGPUB	2003/04/30 15:02
-	12	("20010000240") Or ("20010028983")).PN. (("6420074") or ("6436590") or ("20020083410") or ("20020122994") or ("20020127479") or ("20020129327") or ("20020136964") or ("20020142231") or ("20020142232") or ("20020144232") or ("20020152454") or ("20020155363")).PN.	USPAT; US-PGPUB	2003/04/30 15:06
_	6	((full or complete or overall) adj phase adj shift\$3 adj (mask or reticle or photomask) same (resist or photoresist)) and 430/5.ccls.	USPAT; US-PGPUB; EPO; JPO; IBM TDB	2003/05/08 17:54
] -	1	("6524752").PN.	USPAT; US-PGPUB	2003/05/08 16:46
-	4	((full adj phase adj shift\$3 or full adj phase) adj (mask or reticle or photomask)) not (((full or complete or overall) adj phase adj shift\$3 adj (mask or reticle or photomask) same (resist or photoresist)) and 430/5.ccls.)	USPAT; US-PGPUB; EPO; JPO; IBM_TDB	2003/05/08 16:56

<pre>same (second adj (mask or photomask or US-PGPUB; reticle))) not (((430/5,311-312,319,394,396 or 355/53,77 IBM_TDB</pre>	05/13 18:49
reticle))) not (((430/5,311-312,319,394,396 or 355/53,77 IBM_TDB	
(((430/5,311-312,319,394,396 or 355/53,77 IBM_TDB	
or 378/34-35 or 716/19-21).ccls. and	
(phase adj shift\$3 same (mask or photomask	
or reticle)) same (trim or ((mask or	
photomask or reticle) near3 set) or	
(second or complementary) adj (mask or	
photomask or reticle) or overla\$5)) not	
((((((phase adj shift\$3 same (mask or	
photomask or reticle)) same (resist or	
photoresist or photosensit\$4)) and (trim	
or ((mask or photomask or reticle) near3	
set) or (second or complementary) adj	
(mask or photomask or reticle) or	
overla\$5)) and (transistor near3 gate or	
gate adj shr?nk\$3)) and (resolution or	
resolv\$3)) and (optical adj (parameter or	
configurat\$3) or aperture or (wavelength	
or coherenc\$1 or illumina\$4 or focus or	
defocus) same (expos\$3 or radia\$4 or	
irradia\$4 or light or illumina\$4))))	
- 16 (((dose or dosing or dosage or intensity) USPAT; 2003/9	05/13 18:51
same (second adj (mask or photomask or US-PGPUB;	,
reticle))) not EPO; JPO;	
(((430/5,311-312,319,394,396 or 355/53,77 IBM TDB	
or 378/34-35 or 716/19-21).ccls. and	
(phase adj shift\$3 same (mask or photomask	
or reticle)) same (trim or ((mask or	
photomask or reticle) near3 set) or	
(second or complementary) adj (mask or	
photomask or reticle) or overla\$5)) not	
((((((phase adj shift\$3 same (mask or	
photomask or reticle)) same (resist or	
photoresist or photosensit\$4)) and (trim	
or ((mask or photomask or reticle) near3	
set) or (second or complementary) adj	
(mask or photomask or reticle) or	
overla\$5)) and (transistor near3 gate or	
gate adj shr?nk\$3)) and (resolution or	
resolv\$3)) and (optical adj (parameter or	
configurat\$3) or aperture or (wavelength	į
or coherenc\$1 or illumina\$4 or focus or	
defocus) same (expos\$3 or radia\$4 or	
irradia\$4 or light or illumina\$4))))) and	•
(resist or photoresist) and phase adi	
(resist or photoresist) and phase adj shift\$3 same (mask or photomask or	